

Localized Control of Curie Temperature in Perovskite Oxide Film by Capping-Layer-Induced Octahedral Distortion

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(Received 10 March 2017; revised manuscript received 2 August 2017; published 27 October 2017)

With reduced dimensionality, it is often easier to modify the properties of ultrathin films than their bulk counterparts. Strain engineering, usually achieved by choosing appropriate substrates, has been proven effective in controlling the properties of perovskite oxide films. An emerging alternative route for developing new multifunctional perovskite is by modification of the oxygen octahedral structure. Here we report the control of structural oxygen octahedral rotation in ultrathin perovskite SrRuO₃ films by the deposition of a SrTiO₃ capping layer, which can be lithographically patterned to achieve local control. Using a scanning Sagnac magnetic microscope, we show an increase in the Curie temperature of SrRuO₃ due to the suppression octahedral rotations revealed by the synchrotron x-ray diffraction. This capping-layer-based technique may open new possibilities for developing functional oxide materials.

DOI: 10.1103/PhysRevLett.119.177203

Ultrathin films offer unique possibilities for fabricating novel optical [1], electronic [2], and spintronic [3] devices. In particular, functional complex oxide heterostructures [4] have recently attracted wide attention, in part because the properties of these oxides can be tailored via mechanical strain through the choice of substrates, allowing one to create new materials with desired properties. Large enhancement of ferroelectricity by depositing on strained substrates has been demonstrated in thin films of SrTiO₃ (STO) [5] and BaTiO₃ [6]. Tuning of ferromagnetism with “strain engineering” has been realized in SrRuO₃ (SRO) [7]. An emerging alternative to strain engineering is to modify the oxygen octahedral structure [8]. It has been theorized that distortions to the oxygen octahedra could have large impacts on oxide film’s electrical and magnetic properties [9]. Such distortions have recently been observed to extend several molecule layers (ML) into SRO film [10].

Here we explore a different method of controlling the octahedral distortion, by growing a STO capping layer on top of the SRO film with the hope of tuning SRO’s properties. Since the lateral strain in SRO is largely determined by the substrate, this approach should offer independent controls of strain and octahedral distortion. Experimentally, we indeed observe a large enhancement of Curie temperature (T_C) in SRO with just a few ML of STO capping. Using synchrotron x-ray diffraction, we show that the STO capping changes the oxygen octahedral rotation in SRO film without altering its lateral strain. Density

functional theory (DFT) calculations confirm that this octahedral distortion is the cause for the observed T_C enhancement. Using a scanning Sagnac microscope, we demonstrate localized control of T_C in SRO with spatially patterned capping layer: a unique capability that is lacking in substrate-based approaches. These results may point to new opportunities for functional complex oxides.

The perovskite oxide SrRuO₃ used in this study [11] is a rare case of 4d itinerant ferromagnet with near-perpendicular anisotropy. It is an ideal electrode material to incorporate with a variety of functional complex oxides, including high temperature superconductors. And its itinerant ferromagnetism makes it a possibility as a spin current injector [12,13] or as a spin memory [14]. SRO samples used in this work were grown by pulsed laser deposition (PLD), with film thickness determined by reflection high-energy electron diffraction (RHEED) oscillations. The AFM images of the films [Fig. 1(b)] showed single ML steps indicating an atomically smooth surface typical for a step-flow-like growth mode pointing to a single crystalline quality thin film. These films were grown on DyScO₃ (DSO) substrates, which induce a tensile strain in the SRO films. STO capping layers of varying thicknesses were grown on top of the SRO film *in situ*.

To measure and spatially image the magnetization in ultrathin SRO films we employ a scanning microscope version of the loopless Sagnac interferometer [15], which measures the polar magneto-optic Kerr effect by interfering circularly polarized lights of opposite chiralities. Thus it

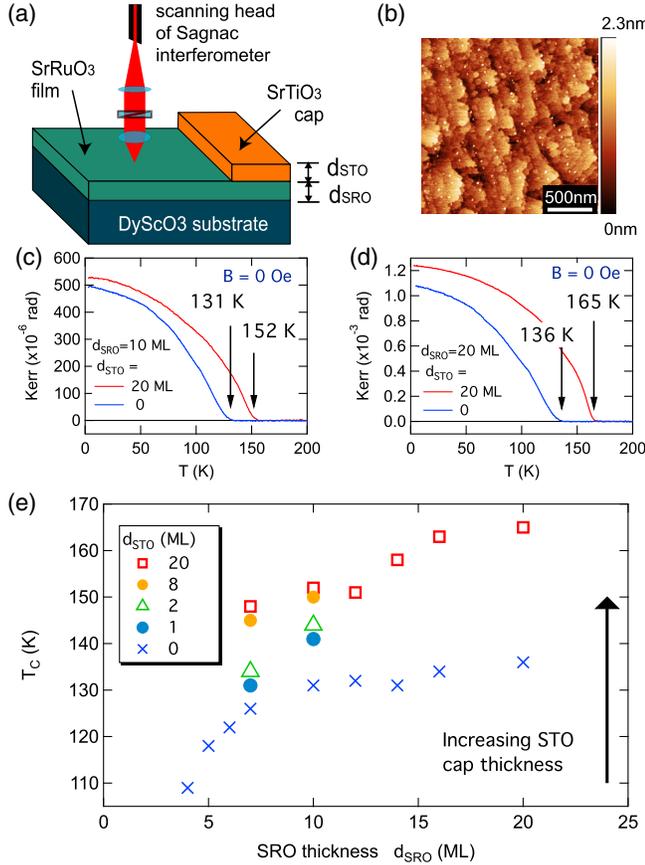


FIG. 1. T_C enhancement in SRO by STO capping layer. (a) Sagnac Kerr measurement configuration. (b) AFM image of 10 ML SRO on DSO substrate with 8 ML STO capping layer. (c) T_C comparison between two 10 ML SRO films: with a 20 ML STO capping layer; uncapped. (d) T_C comparison between capped and uncapped 20 ML SRO films. (e) T_C of SRO films for several combinations of SRO film thickness d_{SRO} and STO capping thickness d_{STO} . STO capping enhances T_C in all samples.

rejects artifact signals that are usually time-reversal symmetry-invariant [16], and has achieved nanoradian level Kerr sensitivity [15]. Since the SRO films used in this experiment are much thinner than the optical skin depth, the measured polar Kerr signal is directly proportional to the film's perpendicular magnetization component [17].

The polar Kerr signals from uncapped SRO films are found to be consistent with a previous study [18]. The ferromagnetic transition (Curie) temperature T_C can be determined precisely by monitoring the remnant Kerr signal at zero magnetic field while warming up the sample. The blue curves in Figs. 1(c) and 1(d) represent such measurements for a 10- and a 20-ML thick SRO films exhibiting the T_C values of 131 and 136 K, respectively, that are close to SRO films grown on STO substrate [18].

We find that adding a few-ML thick STO capping layer induces a dramatic enhancement in T_C . As shown in Fig. 1(c), a 10 ML SRO film with a 20 ML STO capping layer (red curve) has a T_C of 152 K, 21 K higher than its

uncapped counterpart (blue curve). A 20 ML thick SRO film with a 20 ML STO capping shows an even larger T_C enhancement of 29 K [Fig. 1(d)]. Samples with different combinations of SRO film thickness and STO capping thickness were grown and measured. And the results are summarized in Fig. 1(e), where the vertical axis is T_C and the horizontal axis is SRO film thickness d_{SRO} . Different markers represent different STO capping thickness d_{STO} . T_C enhancements up to 30 K are observed in all these combinations. We note that T_C in some configurations has even surpassed the 155 K value in bulk SRO [11].

To understand the origin of the observed T_C enhancement, we performed detailed studies of the changes in SRO thin film structure induced by the STO capping layer employing laboratory and synchrotron x-ray diffraction (XRD). Two samples were examined with the XRD: an uncapped 7 ML thick SRO film (DSO31) and a 7 ML thick SRO film capped with 8 ML STO (DSO84). Both samples were epitaxially grown on DSO(110) substrate in the same growth batch. Reciprocal space maps (RSM) of uncapped and capped SRO films were collected around orthorhombic or pseudocubic $(420)_o/(103)_p$, $(240)_o/(-103)_p$, $(332)_o/(013)_p$, and $(33-2)_o/(0-13)_p$ Bragg peaks using X'Pert materials research diffractometer at the Stanford Nano Shared Facilities. The RSMs (see Supplemental Material Fig. S1, [19]) revealed that SRO layers and the STO cap were coherently strained to the single crystal DSO substrate along the $[1-10]$ and $[001]$ in-plane directions. For the uncapped sample the pseudocubic unit cell of SRO film was determined to be monoclinic and tilted only along the in-plane orthorhombic $[1-10]$ direction of the DSO substrate. No tilt was observed along $[001]$ direction confirming monodomain growth of monoclinic SRO layer. To quantify the out-of-plane lattice parameter and tilt angle of a pseudocubic SRO unit cell, subsequent L scans around pseudocubic (103) , (-103) , and (013) Bragg peaks were collected at the beam line 7-2 of the Stanford-Synchrotron Radiation Light Source (SSRL). The L scans around (103) , (-103) Bragg peaks and corresponding peak fits are shown in Fig. 2. The accurate peak positions of the SRO layer and the STO cap were obtained by fitting the experimental XRD profiles with the corresponding DSO, SRO, and STO Bragg peaks assuming Pearson VII peak shapes. Previous x-ray diffraction studies established that thicker SRO films grown on DSO(110) substrates under tensile stress exhibit tetragonal unit cell with the pseudocubic unit cell parameters $a_p \neq b_p \neq c_p$ and the tilt angle $\beta_p = 90.00^\circ$ [28], following the notations of axes and tilting angles in the Supplemental Material, Fig. S2 [19]. Note that the β_p angle is used to describe the tilt of the pseudocubic unit cell away from the $[001]$ out-of-plane direction. Such a unit cell exhibits an $a^+b^-c^0$ rotational pattern with suppressed out-of-plane rotations due to tensile strain and finite rotations along perpendicular in-plane directions [29]. RuO_6 octahedral rotation angles $\alpha(a^+)$, $\beta(b^-)$, and $\gamma(c^-)$ according to

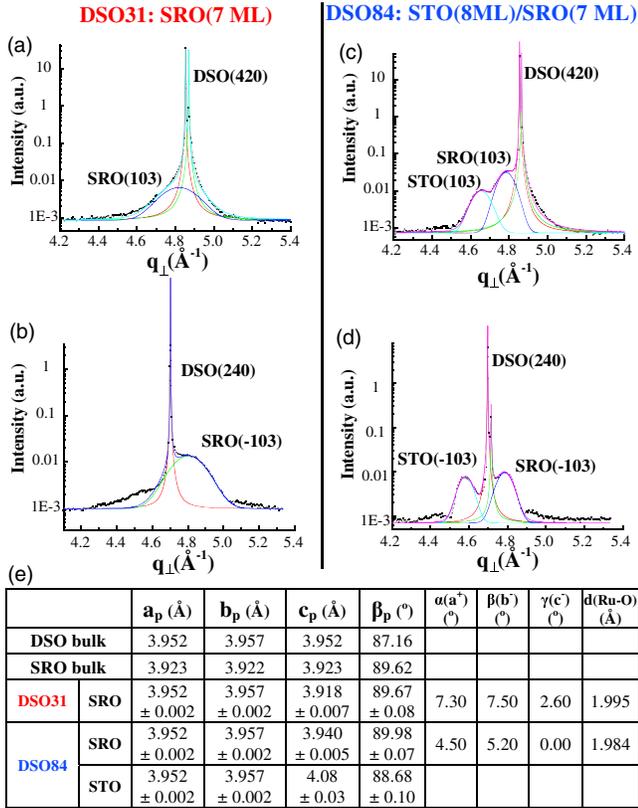


FIG. 2. Structural changes. XRD L scans around $(420)_o/(103)_p$ and $(240)_o/(-103)_p$ Bragg reflections and corresponding peak fittings: (a),(b) for uncapped sample DSO31, and (c),(d) for STO capped sample DSO84. (e) Pseudocubic unit cell parameters and RuO_6 octahedral rotation angles of SRO and STO layers.

Glazer notation signify the in-phase, out-of-phase rotations, and the tilt magnitudes. In Fig. 2 we show that, unlike in the thicker SRO films, in ultrathin SRO layers on the DSO substrate the out-of-plane rotations to some degree are preserved. In Glazer notation for pseudocubic unit cells with $a^+b^-c^0$ rotational pattern, $\beta_p = 90^\circ$. The pseudocubic unit cell with $a^+b^-c^-$ rotations will have a monoclinic shape where β_p deviates from 90° and the crystallographic unit cell will be orthorhombic in this case.

The pseudocubic lattice parameters of all the layers obtained by XRD analysis are summarized in Fig. 2(e). The SRO lateral lattice parameters $a_p = 3.952$ and $b_p = 3.957$ Å are identical between the DSO31 and DSO84 samples, indicating that the STO capping does not change the lateral strain in SRO, unlike in previous substrate-based strain experiments [5–7,30]. The pseudocubic SRO unit cell in the DSO31 sample is monoclinic with $\beta_p = 89.67^\circ$, indicating that SRO film possesses $a^+b^-c^-$ rotational pattern with nonzero out-of-plane rotations. The pseudocubic tilt angle β_p of the SRO layer is slightly larger than in bulk SRO which can be attributed to the effect of tensile strain induced by the DSO substrate. In contrast to the

uncapped SRO film in DSO31 sample, the STO-capped sample DSO84 exhibits a tetragonal unit cell with pseudocubic tilt angle $\beta_p = 89.98^\circ$, resulting in a suppressed out-of-plane octahedral rotation. The pseudocubic unit cell with $\beta_p \approx 90^\circ$ is a direct consequence of unique strain accommodation by the SRO layer in the presence of the STO cap.

Density functional theory (DFT) calculations were performed for SRO with the experimental lattice structure in either the DSO31 or DSO84 sample. Indeed, the later has an exchange energy (defined as $\Delta E_{\text{ex}} = E_{\text{AFM}} - E_{\text{FM}}$) of 39.0 meV, larger than that of the former, 37.1 meV. This indicates that the structural deformation in the SRO layer is the main cause for the capping-induced increase of the Curie temperature T_C . To further disentangle the two factors, lattice strain and the rotation of corner-connected oxygen octahedra, we investigated the magnetic properties of SRO in both orthorhombic and tetragonal structures as depicted in the insets in Fig. 3(a). The ground state orthorhombic phase of SRO has an octahedral tilt angle $\theta = \cos^{-1}[\cos \alpha(a^+) \cos \beta(b^-)]$ of 9.5° away from the c axis, and is 0.3 eV/f.u. lower in energy compared to the metastable tetragonal phase. In both phases, ΔE_{ex} appears to respond rather slowly to the hydrostatic strain V/V_0 , as shown in Fig. 3(a), agreeing with early experiments [31,32], indicating that the lattice strain cannot produce significant change of T_C of SRO. In contrast, ΔE_{ex} of the tetragonal phase is much higher than that of the orthorhombic phase. Moreover, ΔE_{ex} increases very steeply with the reduction of rotational angle away from the orthorhombic phase as shown in Fig. 3(b). As shown in the Supplemental Material [19], our DFT calculations for a STO/SRO/STO film indicate that the octahedral tilts of SRO are reduced by 3.3° to 0.5° from the interfacial to the third SRO layers. This angle is also reduced by about 0.28° in our calculations for bulk structures that mimic the DSO31 (10.84°) and DSO84 (10.56°) samples. Therefore,

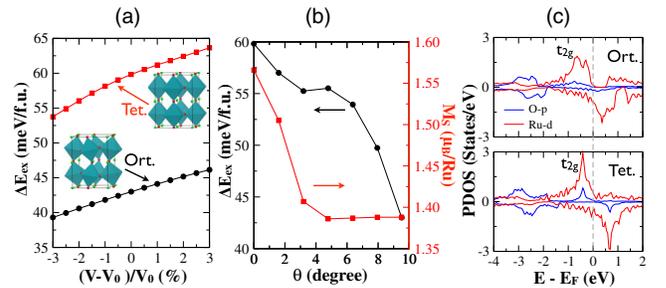


FIG. 3. DFT calculation results. (a) ΔE_{ex} of orthorhombic and tetragonal SRO as a function of hydrostatic strain. The insets show the atomic structures of orthorhombic and tetragonal SRO. The red and green spheres stand for the oxygen and strontium atoms, respectively. The ruthenium atoms locate at the centers of the pseudo-octahedra. (b) ΔE_{ex} and magnetic moment M_s as functions of octahedral tilt angle θ . (c) Projected density of states (PDOS) on O and Ru atoms for the strain-free SRO.

we may attribute the dramatic enhancement of T_C in Fig. 1 to the reduction of octahedral rotation or tilting caused by STO capping. Furthermore, the exchange interaction near the interface is stronger than in the interior region. Nevertheless, SRO is an itinerant magnet; the itinerant electrons spread across the layers; we thus have a singular T_C value even though different layers have different octahedral angles.

The curves of the projected density of states (PDOS) in Fig. 3(c) indicate that the tetragonal SRO becomes metallic in both spin channels, in contrast to the half-metallic feature of the orthorhombic SRO. The spin magnetic moment (M_S) of the orthorhombic SRO is $2.0 \mu_B$ per SRO formula unit, $1.39 \mu_B$ on Ru, in good agreement with previous calculations and experimental measurements [33,34]. M_S of the tetragonal SRO is $2.24 \mu_B$ per SRO formula unit ($1.57 \mu_B$ on Ru), which can be interpreted as the result of higher Stoner instability of SRO in the tetragonal phase. The orthorhombic SRO is an itinerant ferromagnet with the delocalized t_{2g} states solely in the minority spin channel mediating the exchange interaction among Ru atoms. The availability of the itinerant electronic states in both spin channels near the Fermi level leads to a stronger exchange interaction between Ru atoms and, hence, higher T_C . The electronic and magnetic properties of both the orthorhombic and tetragonal SRO do not change much under certain external strain (Supplemental Material, Fig. S4 [19]).

Finally, the reported capping-based technique allows us to control T_C locally. Unlike bulk substrates, the STO capping layer can be patterned lithographically. As shown in Fig. 4, we pattern the 2-ML-thick STO capping layer of a 10-ML SRO film using standard photolithography and etchant mixture of HF, HNO₃, and H₂O [7] that selectively etches STO. The result is a structure illustrated in the inset of Fig. 4(d): region R3 is covered with 2 ML STO, region R1 has no STO capping, and region R2 is covered with 1 ML STO. Since ML-thick STO capping barely changes the optical property, we see uniform optical reflectivity across all three regions. In contrast, all three regions are clearly visible in the Kerr image [Fig. 4(a)], which were taken at zero magnetic field and, hence, the color-bared Kerr signals represent remnant magnetization. Note that the optical cryostat used for scanning imaging in Fig. 4 is equipped with a smaller magnet insufficient to fully saturate SRO's magnetization at low temperatures. Consequently, the remnant magnetization is smaller than what was shown in Fig. 1 where a nonimaging cryostat with a bigger magnet is used. We show in Figs. 4(b),4(d), 4(e),4(f) the Kerr images at different temperatures across ferromagnetic transitions. Consistent with the findings summarized in Fig. 1(e), ferromagnetism onsets at very different T_C for regions R1, R2, and R3. To precisely determine T_C in each region, we perform temperature dependent measurements on several spots as shown in Fig. 4(c). While the Curie temperature is uniform in each

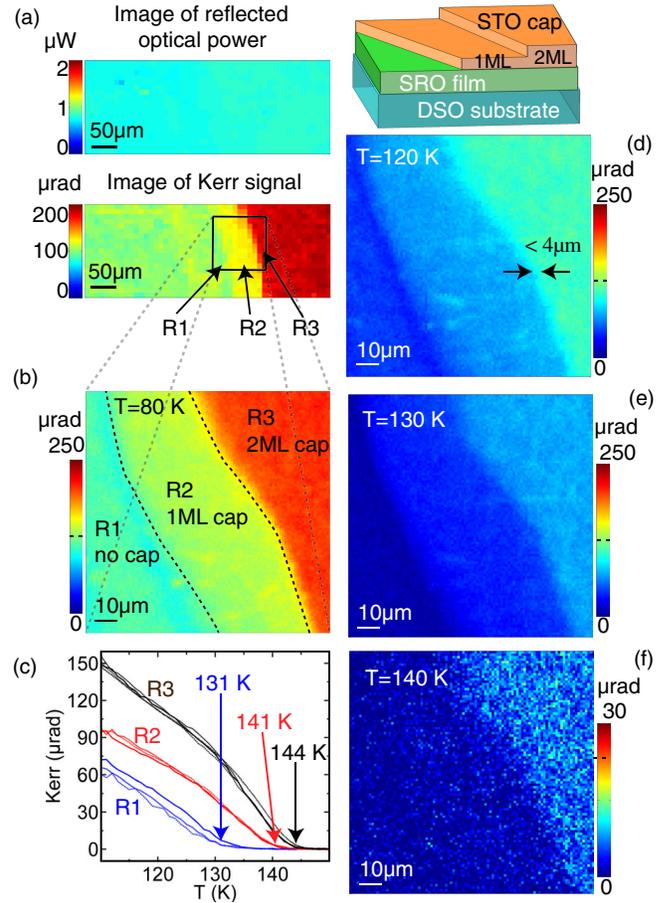


FIG. 4. Local T_C control by patterning the STO capping layer. (a) Scans of the reflected optical power (top) and Kerr signal (bottom) over the transition area between etched and unetched regions of a STO-capped 10ML SRO film. Regions R1, R2, and R3 correspond to 0, 1, and 2 ML of STO capping. (b),(d),(e),(f) Fine scans of the transition region at 80, 120, 130, and 140 K, respectively. (c) Temperature dependent remnant Kerr signal at different spots showing quantitatively uniform T_C within each region, but different T_C between regions.

region, it is quite different between regions: 134 for R1, 141 for R2, and 144 K for R3 as a result of different capping layer thickness. The spatial sharpness of this local control is at least as good as our optical spatial resolution of $2 \mu\text{m}$ [Fig. 4(d)], and it is likely to be ultimately determined by the sharpness of the edge of the STO capping. Furthermore, the restoration of T_C in the region R1 serves as evidence that the diffusion of Ti atoms into SRO is not responsible for the capping-induced enhancement of T_C in this work, as they should not be completely removed by etching.

In conclusion, an enhancement of T_C in SRO thin films due to a STO capping has been demonstrated. XRD measurements reveal diminished oxygen octahedral tilt away from the c axis in the capped SRO layers. This leads to enhanced magnetic exchange energy and, hence, T_C enhancement according to DFT calculations. This capping-layer-based approach allowed us to perform local

T_C tuning, and may provide a new route for property engineering of ultrathin complex oxide materials.

This work is supported by NSF Grant No. DMR-1350122. Sample growth is supported by Netherlands Foundation for Scientific Research (NWO). J.H. and R.W. acknowledge support from DOE-BES Grant No. DE-FG02-05ER46237 and computing time allocation from NERSC. Part of this work was performed at the Stanford Nano Shared Facilities (SNSF), supported by the NSF Grant No. ECCS-1542152. Use of the Stanford Synchrotron Radiation Lightsource, SLAC National Accelerator Laboratory, is supported by the U.S. Department of Energy, Office of Science, Office of Basic Energy Sciences under Contract No. DE-AC02-76SF00515. J.H. thanks the National Natural Science Foundation of China (11574223) and the Natural Science Foundation of Jiangsu Province (BK20150303).

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